

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	6874	700/9,17,83,87,95,96,98,105,108-110,117,121.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 22:11
L2	790	716/21.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 21:53
L3	9959	438/5,7,14,16.ccls. or 700/9,17,83,87,95,96,98,105,108-110,117,121.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 22:11
L4	1590	(shot near2 (sample or layout or lay-out or map\$4))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 22:16
L5	73	(shot near2 (sample or layout or lay-out or map\$4)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 21:54
L6	226378	"438"/\$.ccls. or "700"/\$.ccls. or ("716"/\$.ccls.)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 21:54
L7	12	L6 and L5	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 21:54
L8	481	(global\$2 near2 (alignment or align\$4 or position\$3)) same shot	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 21:54
L9	69	(shot near2 (sample or layout or lay-out or arrangement or arrangment)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 21:54

L10	117	((parameter near2 file) or recipe) near2 (exposure or (extreme near2 UV) or photo-lithograph\$6 or photolithograph\$6 or ebeam or e-beam or EBL or lithograph\$6)	US-PGPUB; USPAT	OR	ON	2005/12/06 21:55
L11	14149	(exposure or shot or layout or pattern) near3 (inspect\$3 or verification or verif\$4 or confirm\$6)	US-PGPUB; USPAT	OR	ON	2005/12/06 21:56
L12	790	716/21.ccls.	US-PGPUB; USPAT	OR	ON	2005/12/06 22:10
L13	2	L12 and "709"/\$.ccls.	US-PGPUB; USPAT	OR	ON	2005/12/06 22:11
L14	793	716/21.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 22:36
L15	1345	709/200.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 22:11
L16	728	700/97.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 22:11
L17	7291	700/9,17,83,87,95,96-98,105,108-110,117,121.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 22:11
L18	1345	L15 and "709"/\$.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 22:11
L19	2	L14 and "709"/\$.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 22:15

L20	2074	382/144-151.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 22:15
L21	279872	((shot or exposure or (extreme adj2 UV) or uv or photo-lithograph\$6 or photolithograph\$6 or ebeam or e-beam or EBL or lithograph\$6 or laser or laserbeam or laser-beam or lazer) near2 (sampl\$3 or test\$3 or measur\$4 or metrology or sens\$3 or detect\$4 or layout or lay-out or map\$4 or alignment or align\$4 or position\$3 or arrangement or arrangment or position\$3 or locat\$4 or grid or pattern\$3))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 22:26
L22	4552	((global or dose) near2 (sampl\$3 or test\$3 or measur\$4 or metrology or sens\$3 or detect\$4 or layout or lay-out or map\$4 or alignment or align\$4 or position\$3 or arrangement or arrangment or position\$3 or locat\$4 or grid or pattern\$3)) same (shot or exposure or (extreme adj2 UV) or uv or photo-lithograph\$6 or photolithograph\$6 or ebeam or e-beam or EBL or lithograph\$6 or laser or laserbeam or laser-beam or lazer)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 22:23
L23	1	"715"/\$.ccls. and L14	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 22:37
L24	4475	((shot or exposure or (extreme adj2 UV) or uv or photo-lithograph\$6 or photolithograph\$6 or ebeam or e-beam or EBL or lithograph\$6 or laser or laserbeam or laser-beam or lazer) near2 (sampl\$3 or test\$3 or measur\$4 or metrology or sens\$3 or detect\$4 or layout or lay-out or map\$4 or alignment or align\$4 or position\$3 or arrangement or arrangment or position\$3 or locat\$4 or grid or pattern\$3)) same (photomask\$3 or photo-mask\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 22:27

L25	3175	((shot or exposure or (extreme adj2 UV) or uv or photo-lithograph\$6 or photolithograph\$6 or ebeam or e-beam or EBL or lithograph\$6 or laser or laserbeam or laser-beam or lazer) near2 (sampl\$3 or test\$3 or measur\$4 or metrology or sens\$3 or detect\$4 or layout or lay-out or map\$4 or alignment or align\$4 or position\$3 or arrangement or arrangment or position\$3 or locat\$4 or grid or pattern\$3)) with (photomask\$3 or photo-mask\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 22:50
L26	11269	L14 or L15 or L17 or L20	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 22:27
L27	106	L25 and L26	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 22:27
L28	20	L14 and (HTML or ML or mark-up-language or ML-language or xml or DTML or (mark adj2 up adj2 language))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 22:49
L29	6	L14 and "345"/\$.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 22:37
L30	65514	"715"/\$.ccls.(photomask\$3 or photo-mask\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 22:50
L31	4	"715"/\$.ccls. and (photomask\$3 or photo-mask\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/06 22:51